INTRODUCTION: Technological advancement in medical device reprocessing requires similar updated monitoring systems in CSSDs cleaning process, equipment, environment and hand hygiene can be monitored effectively for better outcomes. The current CCSD monitoring are qualitative interpretations. Adenosine triphosphate ATP bioluminescence assay measures micro contamination on surfaces expressed in relative light units (RLU) to assess surface cleanliness of reusable medical devices or RMDs, equipment, environment and hand hygiene. This provides a quantitative measurement as a clearer interpretation of surface cleanliness.

METHODS: Processed RMDs are strategically sampled daily on both cleaning utilising an ATP swab sampling. This study will base a ≤50 RLU as the acceptable limit. Environmental surface and related equipment will be monitored weekly with a pass ≤250 RLU. Study will base a ≤50 RLU as limit on related equipment’s internal surface. Hand sampling will done pre and post World Health Organization (WHO) Hand Hygiene (HH) Protocol. A ≤ 50RLU as limit post WHO hand hygiene protocol.

RESULTS: RMD surface monitoring indicate a consistent pass on all surface sampling from the automated and manual cleaning method. Most readings are ≤20 about 93% and the rest is within limit. This resulted to lower the limit to ≤25 RLU. The environmental monitoring provided to change the current environmental wipe. The readings indicate well above recommended ≤250 RLU as high as 1,689 RLU. The switch resulted in readings within ≤37 RLU. Pre HH readings as high as 1687 RLU, post records below 98 RLU. Acceptable limits adjusted to ≤100 RLU.

CONCLUSION: As a singular risk hospital area, CSSD requires a clear and concise monitoring result that provides data to decide on rectifying issues as required. A singular simplified system of quality and risk compliance also enables staff engagement. Straightforward information to determine the level of surface cleanliness in CSSD, in this case a quantitative based data. This provides decisive information necessary for immediate rectification.